[c1] 1.A method of spiking a mixed acid liquid in a reactor by using a computer to control a concentration of the mixed acid liquid, the concentration of the mixed acid liquid being controlled at a target level under a based-on-charge mode, a based-on-time mode, or a based-on-time-and-charge mode,

the based-on-charge mode control comprising:

providing a charge list including a plurality of lot numbers of product and a plurality of spiking amounts of a first acid liquid corresponding lot numbers of product; and

introducing the spiking amounts of the first acid into the reactor in an order corresponding to the lot numbers of product;

the based-on-time mode control comprising:

providing a timing list including a plurality of timing points and a plurality of spiking amounts of a second acid liquid corresponding to the timing points; and introducing the spiking amounts of the second acid liquid into the reactor at the corresponding timing points;

and the based-on-time-and-charge mode control comprising: providing a charge/timing list including spiking amounts and spike timing points; and

introducing the spiking amounts of the first acid into the reactor based on the lot numbers of product and the spike timing points.

- [c2] 2.The method of claim 1, wherein when a wafer is being etched in the reactor, the acid liquid is not introduced into the reactor.
- [c3] 3.A method of spiking a mixed acid liquid in a reactor by using a computer to control a concentration of the mixed acid liquid, the concentration of the mixed acid liquid being controlled at a target level under an even-spike mode, wherein the even-spike mode control comprises:

 providing a timing list including interval settings and spiking amounts of a third acid, wherein the spiking amounts of the third acid are constant; and introducing the spiking amounts of the third acid into the reactor based on the interval settings.

4.A method of spiking a mixed acid liquid in a reactor by using a computer to control a concentration of the mixed acid liquid, the concentration of the mixed acid liquid being controlled at a target level under a based-on-charge mode, wherein the based-on-charge mode control comprises:

providing a charge list including a plurality of lot numbers of product and a plurality of spiking amounts of a first acid liquid corresponding to lot numbers of product; and introducing the spiking amounts of the first acid into the reactor in an order corresponding to the lot numbers of product;

5.The method of claim 4, wherein when a wafer is being etched in the reactor.

5. The method of claim 4, wherein when a wafer is being etched in the reactor, the acid liquid is not introduced into the reactor.

6. A method of spiking a mixed acid liquid in a reactor by using a computer to control a concentration of the mixed acid liquid, the concentration of the mixed acid liquid at a target level being controlled under a based-on-time mode, wherein the based-on-time mode control comprises: providing a timing list including a plurality of spike timing points and a plurality of spiking amounts of a second acid liquid corresponding to the spike timing points; and

introducing the spiking amounts of the second acid liquid into the reactor at the corresponding spike timing points.

7. The method of claim 6, wherein during a wafer is being etched in the reactor, the acid liquid is not introduced into the reactor.

8.A method of spiking a mixed acid liquid in a reactor by using a computer to control a concentration of the mixed acid liquid, the concentration of the mixed acid liquid being controlled at a target level under a based-on-time-and-charge mode,

wherein the based-on-time-and-charge mode control comprises: providing a charge/timing list including spiking amounts and spike timing points; and

introducing the spiking amounts of the first acid into the reactor based on lot numbers of product and the spike timing points.

[c5]

[c6]

[c7]

9. The method of claim 8, wherein when a wafer is being etched in the reactor, the acid liquid is not introduced into the reactor.